Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L17	149	((wafer or substrate or semiconductor or workpiece or electronic$8) near15 (rotated or rotating or rotate or spin or spinning or rotor or centrifug$8) near15 (water or liquid or rins$8 or wash or washing or washer or clean$8 or decontaminat$8 or immers$8 or souc$8 submerg$8 or bath)) and (("o.sub.3" or ozon$8) near15 (gas or atmosphere or environment or gaseous or nebuliz$8 or vapor or fog or aerosol) near15 (hot or heat or heater or heated or heating or temperature))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/13 23:13